

IPW



Docket No.: 65781-014

**PATENT**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of	:	Customer Number: 20277
Yoshihiko NEMOTO, et al.	:	Confirmation Number: 6548
Application No.: 10/629,695	:	Group Art Unit: 2813
Filed: July 30, 2003	:	Examiner: Smoot, Stephen W

For: METHOD OF MANUFACTURING A SEMICONDUCTOR DEVICE WITH  
PENETRATION ELECTRODES THAT PROTRUDE FROM A REAR SIDE OF A SUBSTRATE  
FORMED BY THINNING THE SUBSTRATE (As Amended)

**AMENDMENT**

Mail Stop Non-Fee Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

The following Amendment and Remarks are submitted in response to the Office Action  
dated August 5, 2004. Please amend the above-identified application as follows.